Light em ission from Na/Cu(111) induced by a scanning tunneling microscope

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M easurem ents of light em ission from a scanning tunneling m icroscope probing a N a overlayer on the (111) surface of C u are reported along with results of a model calculation that essentially agree with the experim ental ones. The observed light em ission spectra show two characteristic features depending on the bias voltage. When the bias voltage is smaller than the energy of the second quantum well state formed outside the N a overlayer the light em ission is due to a plasm on-mediated process, while for larger biases light em ission is mainly caused by quantum well transitions between the two levels.

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I. INTRODUCTION

The form ation of quantum well states (QWS) near the Ferm i level is a characteristic feature of the electronic structure of alkali overlayers on the (111) surfaces of noble metals. 1,2,3,4,5,6 In these systems electrons may be conned to a narrow surface region; they cannot escape from the surface because of the vacuum barrier, and at the same time they cannot propagate into the noblem etal because the periodic potential in the bulk creates a local band gap near the L point of the Brillouin zone. Alkali overlayers thus o er an interesting opportunity to study conned electron systems in metals and they have attracted considerable interest.

Up to now, most investigations of alkali overlayers have been carried out using photoem ission spectroscopy (PES), inverse photoem ission spectroscopy (IPES) and two-photon photoem ission (2PPE). 2,7,8,9,10 Thus the energies of the quantum well states have been studied as a function of substrate and overlayer material as well as overlayer thickness (or coverage). In addition to measuring the position in energy of the quantum well states, the lifetimes of these states have also been addressed. 11,12,13 The quantum well states overlap in energy and space with three-dimensional states, producing interesting possibilities for quasiparticle decay to proceed simultaneously through both two-and three-dimensional channels as well as electron-phonon scattering.

In a recent experiment the system Na/Cu(111) was studied with an alternative experimental technique, light em ission induced by electron injection from the tip of a scanning tunneling microscope (STM). 14 This technique has previously been used in studies of quite a few systems, most notably noble metal surfaces and semiconductors. 15 In those cases photons are generated by a fraction of the tunneling electrons that undergo inelastic tunneling processes in which an amount of energy, limited to eU with U the bias voltage, is transferred from the electron to the photon. If the substrate is metallic, the

rate of spontaneous light em ission is increased compared with the case of inverse photoem ission from an isolated surface. 16,17,18,19,20,21,22,23,24,25 This is due to enhanced vacuum uctuations of the electromagnetic eld in the tunnel gap between tip and sample as a result of the formation of localized interface-plasmon modes there. For sem iconductor samples, on the other hand, electromagnetic e ects are less in portant, instead the light em ission is due to interband transitions in the sem iconductor. 26,27 The STM tip serves to locally inject or generate minority charge carriers which then recombine with majority carriers giving rise to luminescence. Similar studies have also been carried out on semiconductor surfaces, 28,29 semiconductor quantum wells and quantum dots, and adsorbed molecules. 32,33

Interestingly enough, the light emission from Na/Cu(111) reported in Ref. 14, appears to involve both mechanisms described above. For a wide range of coverages, Na on Cu(111) exhibits several QWS. The lowest one, QW S1, has an energy close to the Fermi level (see Table I). At the coverages to be discussed below, it is either occupied or unoccupied. The other state, QW S2, lies well above the Ferm i energy. As long as the bias voltage is low enough that electrons cannot be injected into QW S2 light emission is still possible, and it proceeds through the same \plasm on-m ediated" m echanism as in the case of clean noble-m etal surfaces. In this case electrons undergo an inelastic transition from a led state in the tip to the empty QW S1 and a photon is emitted. This gives a fairly broad peak in the light emission spectrum. Once the bias voltage is high enough that electrons can be injected directly into the upper quantum well state (QW S2) the emission m echanism changes. A large part of the tunnel current will now go through QW S2, and light emission will mainly be due to transitions between QW S2 and QW S1, yielding a fairly sharply peaked spectrum. Of course, since the QWS wave functions are to a large extent con ned to the region of space between the tip and

sample, the light emission rate is still enhanced by the electromagnetic uctuations there.

In this paper we will support the scenario outlined above by model calculations that lead to very good qualitative agreement between experiment and theory. We will also present additional experimental results.

The rest of the paper is organized in the following way. In Section II we outline the experimental setup, and the experimental results are presented in Sec. III. Section IV gives a comprehensive description of the model calculation that we have carried out. Next, in Sec. V, we compare theoretical and experimental results and discuss the implications. The paper is summarized in Sec. VI. Finally, an Appendix presents a derivation of the rate of light emission based on the Keldysh non-equilibrium G reen's function technique.

II. EXPERIM ENTAL DETAILS

The experiments were performed with an ultra-high vacuum (UHV) STM operated at a temperature T = $4.6~\rm K$. 34 Photons in the energy range $1.2~\rm eV$ < h < 3.5 eV were detected with a lens-system in UHV coupling the light to a grating spectrometer and a liquid nitrogen cooled charge-coupled device camera. 35 All spectra have been corrected for the wavelength dependent detection e ciency. Throughout the measurements it was veried that the surface structure was not modified during data acquisition.

W tips were prepared by electrochemical etching and subsequent sputtering and annealing in UHV. The Cu(111) surface was cleaned by repeated cycles of Ar-ion bom bardment and annealing. Na lms were evaporated from outgassed SAESG etters sources onto the Cu crystal held at room temperature. A quartz crystalmicrobalance was used to estimate the coverage which was further calibrated by the known binding energies of the quantum well states. 2,7,8,9,10 After preparation at room temperature the sample was transferred to the STM and cooled to T = 4.6 K.

Following Ref. 36 we de ne 1 m onolayer (ML) as the most densely packed structure of the rst Na layer, namely a (3=2 $\,$ 3=2) mesh. This pattern corresponds to 4 Na atom sper 9 rst layer Cu atom s.

III. EXPERIM ENTAL RESULTS

Figure 1 shows unrescence spectra recorded over a range of sample voltages U from Cu(111) covered with 1 m onolayer of Na. The emission from these surfaces is comprised of two distinct components. First, there is an emission band which is most clearly observed at low U. Its maximum shifts linearly to higher energies as U is increased. This emission is similar to the plasmonmediated emission observed from noble metal surfaces due to inelastic tunneling processes. 17,18,19,21,37

A new spectral structure, the position of which only weakly depends on the sample voltage U, emerges at $h=2.4\,\mathrm{eV}$ when the bias is raised to U > $2.5\,\mathrm{V}$. From its intensity, assuming isotropic emission, a quantum eciency of roughly 10^{-5} photons per electron is estimated which is higher than typical values for conventional inverse photoelectron spectroscopy.

Qualitatively similar observations were made at other coverages (Fig. 2). In addition to a plasm on-related emission (circles) at low bias voltages we not emission (dots) at higher photon energies which are almost independent of the applied sample voltages. The positions of these emission features vary with the Na coverage: h 1.7, 2.5, and 2.1 eV at coverages 0.6, 1, and 2 M L, respectively. Comparing these photon energies to the data of Table I the emission is assigned to interband transitions between quantum well states. Small deviations between the expected transition energies (E $_2$ E $_1$) and the measured photon energies are in part due to the electric eld of the tip which causes a Stark shift. 38,39,40 This shift is strongest for higher energy states.

C loser inspection reveals a distinct di erence of the data from 0.6 and 2 M L compared to the 1 M L case. At 1 M L coverage, a sharp drop on the high energy side of the em ission occurs owing to energy conservation given by the condition $h\ =\ eU$. The em ission from the 0.6 and 2 M L Na $\ lm\ s$ exhibits a similarly sharp drop at a di erent energy, $h\ =\ eU\ E_1$, where E_1 is the energy of quantum well state 1 relative to the Ferm i level.

TABLE I: Energies of quantum well states of N a on C u (111) in eV relative to the Ferm ienergy E $_{\rm F}$ as obtained from tunneling spectroscopy of the di erential conductance. At a coverage of 1 m onolayer, the lowest state is occupied (E $_1<$ 0).

	0.6 M L	1 M L	2 M L
E 1	0.4	-0.15	0.15
E 2	2.05	2.3	2.2

IV. MODEL AND THEORY

A. General considerations

In this section we will use a rather simple, basically one-dimensional model of the W-tip/Na/Cu (111) system that nevertheless captures the essential physics of the experiment and yields calculated spectra that can explain the experimental results.

The general framework of this calculation is based upon what we have used in earlier calculations 18,41 of light em ission from noble metal surfaces. As the more detailed derivation in the Appendix shows, the intensity of the em itted light (per unit photon energy and solid

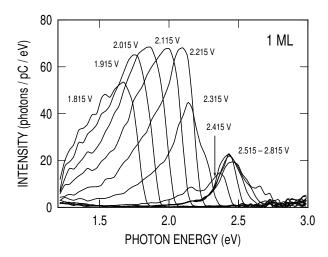


FIG. 1: Light em ission spectra of 1 M L N a m easured for a series of sample voltages between 1.815 V and 2.815 V with a tunneling current of 10 nA . Sm all apparent undulations at low ($^{<}$ 1:6 eV) and high ($^{>}$ 2:6 eV) photon energies are due to counting statistics. There is a qualitative change once the voltage reaches $2:5$ V:Below, the peak em ission shifts with the sample voltage; above, the em ission maximum remains at h $2:4$ eV .

angle) can be calculated from the expression

$$\frac{dP}{d(h!)d} = \frac{2}{h} \sum_{i,f}^{X} j_{fi} j^{f} \frac{f(!)j^{f}}{(2)^{3}} \frac{h!^{2}}{2_{0}c^{3}} (E_{i} E_{f} h!):$$

Thus, the intensity is found from a sum mation over led initial electron states i and empty nal states f, and $j_{\rm fi}$ is the current matrix element between these states,

$$j_{fi} = \frac{ieh}{2m}^{Z} d^{3}r \frac{\theta_{f}}{\theta_{Z}} i f \frac{\theta_{i}}{\theta_{Z}} : \qquad (2)$$

In Eq. (1), $_{0}$ is the perm ittivity of vacuum and c the speed of light, and G , nally, is an electrom agnetic enhancem ent factor. Note that Eq. (1) agrees with Eqs. (6) and (7) of Ref. 41, considering that the formulas in that work employed CGS units.

Since the calculation of G (!) in Eq. (1) has been treated in earlier papers (see, for example, Ref. 42) we will just give a brief outline of the procedure here. As discussed in the Appendix, a reciprocity relation makes it possible to interchange the source and detection points in the electrom agnetic calculation. Thus, since we are interested in evaluating the light em ission intensity found at an observation angle = 1 rad, we let an incident electrom agnetic wave hit the tip-sample system from exactly that direction and calculate the electric eld enhancement at a point between the tip apex and the surface, where it reaches its highest values. The eld in the cavity between the tip and sample is essentially constant along the direction normal to the surface, however, in the lateral direction the eld enhancement begins to drop o at distances exceeding 2{3 nm from the symmetry axis.

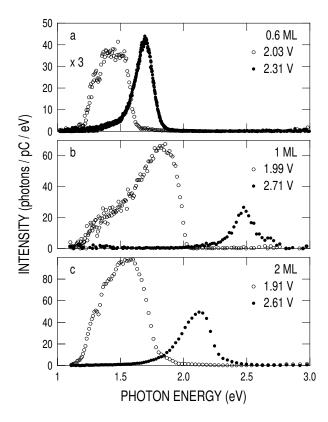


FIG. 2: Characteristic spectra, obtained with a low sample voltage (circles) for which injection of electrons into the upper quantum well state is not possible, and a high sample voltage (dots) where electrons can be injected into the upper QWS. The three panels display results from samples covered by 0.6, 1, and 2 m onolayers of Na. A small dip of the intensity at 1:3 eV is due to a sharp absorption of the optical berused in the experiment, which is not fully corrected for.

The optical properties of tip and sample are modeled using macroscopic dielectric functions for Cu and W found from Ref. 43. We have approximated the optical properties of the Na layer by the Cu dielectric function since the treatment of such a thin layer in terms of macroscopic dielectric functions would not be very reliable. The tip is represented by a sphere with radius $R=30\,\mathrm{nm}$.

B. M odelpotential

We use a one-dimensional model potential, illustrated in Fig. 3, to calculate both the tunneling current and the matrix elements that set the lightem ission rate. The parameter values that enter this model originate from the physical properties of bulk C u and bulk N a that are most relevant to the problem at hand. Similar models have been used in earlier calculations 45,46 (see also Ref. 47).

Of course, using a strictly one-dimensional model corresponds to a situation where both electrodes, sample and tip, are completely at. This is not the real situa-

tion in an STM experiment. Thus, we use the 1D model to calculate a current density which then multiplied by a suitable e ective area yields the tunnel current. A similar procedure is applied for the matrix-element calculations as well.

Inside the copper sample the potential is modulated along the (111) direction (normal to the surface) as

$$V_{Cu}(z) = V_{111}(e^{igz} + e^{igz}) = 2V_{111}\cos(gz);$$
 (3)

where the reciprocal lattice wave vector $g = 2 = a_{Cu}$, and $a_{Cu} = 2.08 \text{ A}$ is the inter-plane distance in Cu in the (111) direction. The top layer is centered at z = 0, and the copper sample is assumed to end at $z = z_{Cu} = a_{Cu} = 2$. The value of V_{111} is taken to be 2.5 eV. ⁴⁶ The potential in (3) yields a band gap for energies (related to electron m otion in the z direction) between E $_{\rm g}$ $\,$ V $_{\rm 111}$ and E $_{\rm g}$ + $\,$ V_{111} , where $E_g = h^2 (g=2)^2 = (2m)$ 8:7 eV is the kinetic energy of a free electron with a wave vector at the L point on the Brillouin zone boundary. Thus, just as in copper our model has a 5 eV wide band gap at the L point. This feature is crucial in forming quantum well states in the overlayer system . Experim entally the energy di erence between the lower band edge and the Fermi level is 0.9 eV, we therefore put the Cu Ferm i level at $E_F = E_q V_{111} + 0.9 \text{ eV} = 7.1 \text{ eV}$.

We treat the sodium overlayer as a bulk, free-electron metal. The thickness is assumed to correspond to 2 monolayers (6.13 A). The constant value of the potential in the sodium is set to $V_{\rm N\,a}=3.9~{\rm eV}$. The choice of this value is based on the fact that the Ferm i energy of bulk Na is 3.2 eV, so that now an electron with the kinetic energy of 3.2 eV in the Na layer will have a total energy of (3.9 + 3.2) eV = 7.1 eV, i.e. identical to E_F.

M oreover, in order to get a tunnel current from electrons with energies in the Cu band gap, it is necessary to add a negative imaginary part to the potential. We have chosen to put this in the sodium layer, thus the full Na potential is

$$V_{Na}$$
 i; with = 0:1eV:

in an approximate way represents the e ects of electron-phonon, electron-electron, and interface scattering that in the real system eventually remove electrons from the quantum—well states near the surface. If the potential had this value in all of space, the electron density due to a particular state would decay in time as e 2 t=h . Thus the lifetime would be =h=(2) 3 fs, and the peak in the spectral function associated with the state would have a full width at halfmaximum of 2 . It must be kept in mind that an electron in a QW S only spends part of the time ($50\,\%$ for QW S1) in the Na layer. Our choice for would thus give a lifetime of some 6 fs, and a line width of 0.1 eV for QW S1. These values are comparable with measured values found in the literature. 48

We have for simplicity assumed that the potential is constant in the W tip. This is of course a rather crude approximation, but not a crucial one since the electronic structure of the tip is not of primary importance for the analysis of the experiment at hand. W ith the free-electron band width W = 8.0 eV, the potential in the tungsten tip at zero bias is $V_{\rm tip}=E_{\rm F}$ W = 0.9 eV, however, when the tip is biased the potential is given by $V_{\rm tip}=E_{\rm F}$ W + eU .

Finally, we need a barrier potential to use in vacuum between the Na overlayer and the tip. This potential essentially consists of two parts: a tilted square barrier and image potential contributions. The tilted square barrier can be written

$$V_{\text{tilt}}(z) = \frac{z_{\text{tip}} - z}{d} (E_F + N_a) + \frac{z - z_{Na}}{d} (E_F + eU + t_{\text{tip}});$$
(4)

where $z_{\rm tip}$ is the coordinate of the tip apex, $z_{\rm N\,a}$ is the coordinate of the Na overlayer surface, and d is the tipsample separation. Here $_{\rm N\,a}=2.7$ eV and $_{\rm tip}=5.2$ eV denote the Na and tip work functions, respectively, and U is the bias voltage. The image contributions are

$$V_{im}(z) = \frac{e^2}{4_{0} 4(z z_{Na}^{im})} \frac{e^2}{4_{0} 4(z_{tip}^{im} z)} : (5)$$

We have chosen the image plane position as

$$z_{Na}^{im}$$
 $z_{Na} = e^2 = [16 \ _0 (_{Na} + E_F \ V_{Na})]$ (6

in the sample. This guarantees that the total potential $V_{\text{tilt}} + V_{\text{im}}$ equals $V_{\text{N a}}$, the potential inside N a, at $z = z_{\text{N a}}$ provided the tip is far away. In the tip, following the same reasoning,

$$z_{\text{t.ip}}^{\text{im}}$$
 $z_{\text{t.ip}} = e^2 = [16 \ _0 \ (_{\text{t.ip}} + W \)]$: (7)

The resulting potential is illustrated in Fig. 3 for two di erent values of the bias voltage.

The model potential described above yields an electronic structure of the Na overlayer that is in reasonable agreement with experimental observations. In particular, using this model we are able to reproduce the essential features found in the experiment by Homann, Kliewer, and Berndt. At the same time it should be pointed out that the model is not detailed enough to reproduce exactly the same energy level positions as found experimentally. Given that the Na layer is modeled using bulk parameters, the theoretical results should be more accurate for thicker overlayers. We have therefore concentrated on calculating results for the 2-monolayer case.

C. W ave functions

To calculate the tunnel current and subsequently the light em ission intensity we must solve the Schrodinger equation for the electron wave functions. Since we have chosen to work with a potential that is translationally invariant in the directions perpendicular to the tunneling direction, we can write all wave functions on the form

$$(r) = (z)e^{iK_k - \frac{\pi}{k}}$$
: (8)

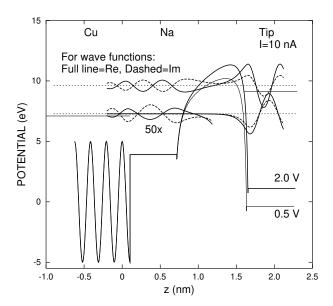


FIG. 3: Illustration of the model potential at two di erent values of the bias voltage. In addition the wave functions corresponding to the two quantum well states have been calculated using boundary conditions corresponding to an electron impinging on the barrier from the tip side when $U=2\ V$. Note that the wave function at the QW S2 energy penetrates the barrier with high probability, however, since this energy here lies above the tip Ferm i energy, this does not contribute to the tunnel current.

In the copper sample, in view of the potential given by Eq. (3), we make the nearly-free electron model Ansatz

$$(z) = e^{ikz} + e^{i(k g)z}$$
 (9)

for the wave function. Inserting this into the Schrodinger equation one nds that there is a band gap for energies (related to the motion in the z direction) between E $_g$ V₁₁₁ and E $_g$ + V₁₁₁. In this energy interval there are no bulk states in the copper, however, one can still have surface states for which k = p iq with p = g=2, and

Thus, the wave function envelope decays exponentially as e^{qz} and the electron is con ned to the region near the copper surface. Since we use a positive value for the corrugation of the potential $(V_{111}=2.5~{\rm eV})$ states near the bottom of the gap will be p-like, whereas states near the top of the gap are s-like.

The wave function in Na takes the form

$$(z) = A e^{ik_{Na}z} + B e^{ik_{Na}z};$$
 (10)

where $k_{N\,a}=\frac{p}{2m}$ $\frac{}{2m}$ (" $V_{N\,a}+i$)=h and the branch cut of the square root function is placed along the negative real axis so that the imaginary part of $k_{N\,a}$ is positive. In the barrier region, the wave function must be integrated numerically and then pined to the tip wave function

$$(z) = C e^{ik_{tip} z} + F e^{ik_{tip} z};$$
 (11)

(with $k_{tip} = \frac{p}{2m \text{ (" } V_{tip})} = h$) at $z = z_{tip}$. The coe - cients C and F, as well as A and B in Eq. (10), must be determined by wave function m atching.

D. Tunnelcurrent

Before we can evaluate the matrix elements entering Eq. (1) we have to calculate the tunnel current $I_{\rm dc}$, or rather, determine the tip-sample separation d that yields a certain, set value for $I_{\rm dc}$. The probability current density in the z direction associated with one particular wave function can be written

$$j = \frac{1}{A_e} \frac{1}{f^2 f^2} Re[(z) \frac{\hat{p}_z}{m} (z)];$$
 (12)

Here the $\,$ rst two factors serve as normalization. A $_{\rm e}$ $\,$ is the e ective area of the tunnel contact, which we also use as a normalization area for the wave functions, 49 L is a normalization length (in the tip), and by dividing by F f we normalize the current to the current carried by the wave impinging on the barrier from the tip side. For a real-valued potential the probability current j is independent of the z coordinate. In the present case, with a potential that has a non-zero imaginary part in the sodium layer, the probability current is independent of z to the right (in the barrier and tip) of the Na layer, and can be evaluated anywhere in that part of space. j vanishes, on the other hand, in the copper since we cannot have any propagating states in the energy gap there. A tunnel current is owing across the tunnel gap only because of the scattering processes that eventually scatter electrons out of the quantum well states con ned to the N a overlayer and surface region of the copper.

The total electric current is obtained by sum m ing over all contributing states to get a total current density and then multiply by the electron charge and the electron tunneling area

$$I_{dc} = eA_e \quad j : \tag{13}$$

This sum can then be turned into an energy integral.

E. Intensity of em itted light

To calculate the di erential power of the em itted light we must carry out the sum over initial and nale ectron states as indicated in Eq. (1). In contrast to the case of light em ission from noble metals the nale ectron state is in this case, at least in one sense, discrete. Light is primarily em itted while the electron traverses the vacuum barrier and then QW S1 is in practice the only possible nal state (assum ing parallel momentum is conserved); it dom inates the local density of states completely in the energy range just above the substrate Ferm i level.

Therefore in the calculations, we have solved for a bound state to represent $_{\rm f}$. This state is calculated with essentially the same potential as was used for the tunnel current calculation, however, in this case we set equal to zero, and determ ine an energy eigenvalue by requiring that the wave function is decaying well inside the tunnel barrier. In the x and y directions this bound state wave function is assumed to behave like a planewave state with a certain momentum. Furthermore, in the following we will assume that this state is almost always unoccupied so that tunneling electrons can make

inelastic transitions into it and em it light at the same time. This last assumption is reasonable because even if most of the tunnel current passes via QW S1, the lifetime of this state is of the order 10 $^{14}\,$ s while with a tunnel current of 10 nA the delay between each tunnel event is 1:6 $\,$ 10 $^{11}\,$ s.

In our one-dim ensional model the momentum parallel to the interfaces and the electron spin is conserved in the inelastic tunneling process. The sum over initial and nal states in Eq. (1) then reduces to integrals over parallel and perpendicular momentum,

$$\frac{dP}{d(h!)d} = \frac{!^{2}f(!)f^{2}}{8^{2}c^{3}} I_{i:f} I_{fif} I_{fif} E_{i} E_{f} h!) = 2\frac{!^{2}f(!)f^{2}}{8^{2}c^{3}} A_{e} L^{Z} \frac{dk_{z}}{2} I_{fif} I_{fif} E_{i} E_{f} h!); (14)$$

Here the integration over parallelm omentum can be turned into an energy integration over an interval starting at zero and ending at the maximum energy $E_{k,m}$ ax that the electron can have due to the motion parallel to the interfaces. This energy is given by the tip Ferm ienergy, i.e. E_F + eU minus the z motion energy E_f + h! in the initial state, i.e. $E_{k,m}$ ax = E_F + eU E_f h! . We then get

$$\frac{dP}{d(h!)d} = 2 \frac{!^{2} f_{S}(!) f_{S}^{2}}{8^{2} o^{3}} A_{e} L \frac{m E_{kmax} (E_{kmax})}{2 h^{2}}^{Z} \frac{dk_{z}}{2} jj_{fi} f_{S}^{Z} (E_{i} E_{f} h!);$$
(15)

where denotes a step function. It remains to carry out the k_z integration, and also this is, in view of the function in the integrand, straightforward. If we let E_b stand for the band bottom energy in the tip, one has $h^2k_z^2=(2m)=E_i$. It is then possible to show that

$$k_{z} + \frac{q}{2m (E_{f} + h! E_{b}) = h^{2}};$$

$$(E_{i} E_{f} h!) = \frac{\frac{h}{m} P}{2m (E_{f} + h! E_{b})};$$
(16)

and when this is inserted into Eq. (15) we get the nal result

$$\frac{dP}{d(h!)d} = A_e \frac{e^2!^2 jG(!)j^2 (E_F + eU E_1 h!) (E_F + eU E_1 h!)}{64^4 ohc^3} \frac{E_F + eU E_1 h!) (E_F + eU E_1 h!)}{2m (E_1 + h! E_b)} dz \frac{e^2}{e^2} i \frac{e^2}{e^2} i (17)$$

Note that we have made the replacement $E_{\rm f}$! $E_{\rm 1}$ in the last equation because the nal state here is identical to the lowest QW S. The z integration is limited to the vacuum part of space, since the electromagnetic eldenhancement is much higher there than in the tip and sample.

V. RESULTS AND DISCUSSION

Figure 4 shows spectra calculated from the model of Sec. IV for a number of dierent bias voltages. The calculated tunnel current was kept constant at $I_{\rm dc}$ = 10 nA in all cases by changing the tip-sam ple separation.

We see that these spectra have a number of general qualitative features in $com \, m$ on with the experimental

spectra shown in Figs. 1 and 2. At rst, for bias voltages < 2.5 V, the spectrum has a relatively broad peak that is cut o on the high-energy side. Since QW S1 is the nal state in the light em ission process the maximum photon energy equals eU (E₁ E_F), and not eU, [cf. Eq. (17)].

Once the bias voltage becomes high enough that electrons can be injected into the upper QWS most of the tunnel current will take this path. At the same time the tip-sample separation increases to maintain the tunnel current at a constant value. Quite naturally the electrons injected into the upper QWS will also dominate the lightem ission processes at these higher voltages. Most of the emitted photons will have an energy closely corresponding to the energy dierence between the two quantum well states.

Returning to the model, these facts can be understood as follows. As long as the tip Ferm i energy lies below

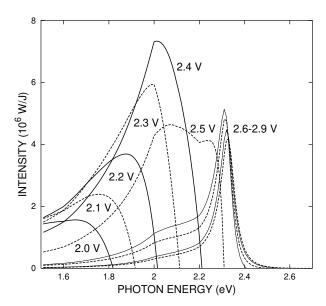


FIG.4: Calculated light em ission spectra for the Na/Cu (111) system with an overlayer thickness corresponding to 2 monolayers. The spectra were calculated for a series of bias voltages, while the tunnel current was kept xed at 10 nA by varying the distance between tip and sample.

QW S2 all initial state wave functions will decrease exponentially upon traversing the tunnel barrier. Therefore wave functions $_{i}$, corresponding to a broad range of energies give comparable contributions to the integral in Eq. (17). The shape of the spectrum in this case is mainly determined by the phase space factor $(E_F + eU - E_1 - h!)$ and the eld enhancement factor $(G_F + eU - E_1 - h!)$

For higher bias voltages, when E_F + eU exceeds E_2 , it is instead the last factor in Eq. (17), the matrix element integral, that determ ines the spectral shape. The nal state remains the same and therefore, to have a large matrix element, the initial-state wave function i must be large in the part of space where the nal state resides. This will happen when the initial state energy coincides with E2 since then resonant tunneling into QW S2 is possible and $_{i}$ will look like the upper wave function illustrated in Fig. 3. Even if there are plenty of initial states with energies both som ew hat below and above E2, they will not at all give as large contributions to the em itted light intensity because their wave functions are much smaller near the Na overlayer surface. As a result of this the light em ission spectrum develops a peak around $h = h! = E_2 E_1$.

The overall intensity of the em itted light is smaller at the higher voltages. The main reason for this is that raising the voltage moves the peak of the light em ission spectrum away from the frequency range near 2 eV where a tungsten tip and a copper sample have an interface-plasm on resonance causing resonantly enhanced light em ission. At a photon energy of $2.3\{2.4\text{ eV}$ there is still a considerable eld enhancem ent between the tip and sample, but G is typically down by a factor of 2 com - pared w ith the resonant case. Thus, the peak in the light

em ission spectrum at h 23 eV is entirely due to the special electron structure of the Na/Cu (111) surface.

The experimental results also illustrate the last point in an interesting way. With 1 M L coverage [Figs. 1 and 2 (b)] the emission peak due to quantum well (or interband) transitions falls at a high photon energy where the electrom agnetic enhancement is relatively small. Consequently, comparing spectra taken at dierent voltages, the plasmon-mediated light emission yields the more intense peaks in these spectra. However, for 0.6 M L coverage [Fig. 2 (a)] the quantum well transition occurs at a lower photon energy, near the maximum of the electromagnetic enhancement. In this case the \quantum -well peak is more intense than the peak occurring at the lower bias voltage.

In this context let us discuss why it is reasonable to calculate the electrom agnetic enhancem ent at a point just below the tip apex both for plasm on-m ediated and QW S transition light em ission. In the rst case, this is natural since the light em ission event must take place while the electron tunnels from tip to sample. In the latter case, the electron is injected into a fairly long-lived state, and in principle it m ay end up in a point quite far away from the tip apex before a photon is em itted. However, with a lifetime of 10 fs and a lateral electron velocity of $10^5\,$ m/s the distance traveled by the electron is no more than 1 nm, thus it would still be in a region where the electrom agnetic enhancem ent has not dropped overy much (cf. the discussion in subsection IV A).

From the calculated results, one can estim ate the quantum e ciency of the light em ission process to be 10 5 em itted photons per tunneling electron. This number compares well with the experimental result. It is considerably larger than what is observed for inverse photoem ission processes at a single surface, however, the quantum e ciency of STM -induced light em ission from most notably Ag samples may reach values between 10 4 and 10 3 .

VI. SUMMARY

In sum mary we have interpreted experimental observations of STM -induced light emission from the quantum well system Na on Cu (111) using model calculations of the electronic structure and the optical properties of the tip-sam ple region. The main features of the experimental data, namely two distinct spectral structures, and their intensity variation with the tip-sam ple voltage are reproduced by the calculations. The emission lines are attributed to (a) emission from a localized plasmon which is excited by inelastic tunneling to a quantum well state and (b) transitions between two quantum well states. The electrom agnetic enhancement present in the tip-sam ple cavity substantially enhances the intensity of the emission and explains the observed, high quantum e ciencies.

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APPENDIX A

In this appendix we derive Eq. (1) using the Keldysh non-equilibrium G reen's function (GF) technique. 50,51 W e w ish to calculate the intensity of the spontaneously em itted light at a detection point r_0 far away from the STM tip and sample. Since all photons appearing at this point that are of interest to us originate from the region around the STM tip, the intensity can be found by multiplying the electrom agnetic energy density, excluding the zero-point energy, by the speed of light. The energy density can be expressed in terms of Keldysh GF's as

$$w = i_0 \sum_{0}^{Z_1} \frac{d!}{2} \mathbb{D}_{EE}^{<} (r_0; r_0; +!) + \mathbb{D}_{EE}^{>} (r_0; r_0; !)];$$
(A1)

where D $_{\rm E\,E}^{<}$ (r₀;r₀;!) and D $_{\rm E\,E}^{>}$ (r₀;r₀;!) are the Fourier transforms of

$$D_{EE}^{<}(r_0; r_0; t) = ihE(r_0; 0)E(r_0; t)i$$
 (A2)

and

$$D_{EE}^{>}(r_0;r_0;t) = ihE(r_0;t)E(r_0;0)i;$$
 (A 3)

respectively. In writing these expressions we have assumed that the tunnel current causing light emission ows in the z direction near the origin and sends out p-polarized light with an electric eld E = $^{\rm L}$, pointing in the direction in the far eld. Consequently, the radiated di erential power can be written

$$\frac{dP}{d(h!)d} = \frac{ic_0 r_0^2}{2 h} \mathbb{D}_{EE}^{<} (r_0; r_0; +!) + \mathbb{D}_{EE}^{>} (r_0; r_0; !)];$$
(A 4)

The two K eldysh GF's in Eq. (A4) actually yield identical contributions and in the following we will only deal with D $^{<}$.

W e need to $\,$ nd an expression for the contributions to D $_{\rm E\,E}^{\,<}$ that result from interactions between the electromagnetic eld and the electron system in the STM tip and sample. This interaction is to lowest order

$$H^{0} = \frac{e^{X}}{2m} [A (r_{n}) p_{n} + p_{n} A (r_{n})];$$
 (A.5)

where A is the electrom agnetic vector potential (E = \emptyset A = \emptyset t), the sum runs over the electrons, and r_n and p_n are the electron coordinates and momentum operators, respectively. By performing an S-matrix expansion of D $_{\rm E\,E}^{<}$ to second order in H 0 we nd, using the rules for \analytic continuation", $_{\rm D\,E\,E}^{5}$ that D $_{\rm E\,E}^{5}$ can be expressed as a product of two photon G reen's functions and a current-current G reen's function,

$$D_{EE}^{<}(r_{0};r_{0};!) = \frac{1}{h^{2}} Z Z$$

$$D_{EA}^{r}(r_{0};r_{1};!) ^{<}(r_{1};r_{2};!)D_{AE}^{a}(r_{2};r_{0};!):$$
(A 6)

These G reen's functions are the Fourier transforms of a retarded photon $\operatorname{\mathsf{G}} F$

$$D_{EA}^{r}(r;r^{0};t) = i (t)hE(r;t);A_{z}(r^{0};0)]i;$$
 (A7)

an advanced photon GF

$$D_{AE}^{a}(r;r^{0};t) = i (t)hA_{z}(r;t);E (r^{0};0)]i;$$
 (A8)

and the current-current GF

$$(r;r^0;t) = ihj_z(r^0;0)j_z(r;t)i$$
: (A 9)

The current density operator

$$j_z(r) = \frac{ieh}{2m} y(r) \frac{\theta(r)}{\theta z} (r) \frac{\theta^y(r)}{\theta z}; \quad (A.10)$$

where and $^{\rm y}$ are electron annihilation and creation operators. 52

At this point we can make a number of approximations and simplications. The inelastic tunneling events occur in a very small part of space in the tunnel gap in a region of (sub-)nanom eter size. The photon G reen's functions do not vary very much on this length scale, so D $^{\rm r}$ and D $^{\rm a}$ can be taken outside the integral, and r_1 and r_2 can be replaced by a xed point $r_{\rm s}$ in the tunnel gap in these functions. Fourier transform ation turns time derivatives into frequency multiplications. Therefore the photon G reen's functions only need to involve the vector potential. Moreover, in Fourier space retarded and advanced GF's are each others complex conjugates, and nally the reciprocity theorem of electrodynamics allows us to interchange the source and eld points in the retarded photon GF. This gives us

$$D_{EA}^{r}(r_{0};r_{s};!)D_{AE}^{a}(r_{s};r_{0};!) = !^{2}D_{z}^{r}(r_{s};r_{0};!)^{\frac{2}{2}}$$
(A 11)

In a case where parts of space is led with materials characterized by a relative dielectric function $_{\rm r}$ (r) the (tensor) photon G reen's function D solves 50,53

r r
$$_{r}(r)\frac{!^{2}}{c^{2}}$$
 D $_{r}(r;r^{0};!) = h_{0}^{3}(r r^{0})$ (A 12)

and yields the component of the vector potential in the point r if there is a function current source pointing in the direction in r^0 . Thus, D^r $(r; r^0; !)$ can be calculated within the fram ework of classical electrodynam ics. The z element of interest here can be written

$$D_{z}^{r}(r_{s};r_{0};!) = \frac{h}{0c^{2}} \frac{e^{ikr_{0}}}{4r_{0}} G(0;!); \quad (A13)$$

where G is an enhancement amplitude. G is given by the z component of the local electric eld in the tunnel gap when a plane wave of unit amplitude incident from the direction of r_0 impinges on the tip-sample system. In free space one would simply have $G(;!) = \sin$. The detailed scheme for calculating G has been described earlier, for example in Ref. 42.

It remains to evaluate the current-current G reen's function $(r_1; r_2; !)$ and to carry out the integrations over the coordinates r_1 and r_2 in Eq. (A 6). A straightforward evaluation yields the result

$$Z Z Z d^3 r_1 d^3 r_2 (r_1; r_2;!) =$$

$$= 2 \text{ ih} \quad \text{ij}_{\text{fi}} \quad \text{(h! + E_f E_i)} \qquad \text{(A 14)}$$

where the sum runs over led initial electron states i with energy E $_{\rm i}$ and wave function $_{\rm i}$ and empty nal electron states f with energy E $_{\rm f}$ and wave function $_{\rm f}$, and

$$j_{fi} = \frac{ieh}{2m}^{Z} d^{3}r \frac{\theta_{f}}{\theta_{Z}} i \frac{\theta_{i}}{\theta_{Z}} : \quad (A15)$$

By inserting the results of Eqs. (A6), (A11), (A13), and (A14) in Eq. (A4) we arrive at the nal result

which is identical to Eq. (1).

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